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Form PTO-1449

**INFORMATION DISCLOSURE CITATION IN AN APPLICATION**

(Use several sheets if necessary)

| Docket Number | Application Number |
|---|---|
| 7378/71294 | 09/883,406 |
| **Applicant** | |
| OKAZAKI et al. | |
| **Filing Date** | **Group Art Unit** |
| June 19, 2001 | |

**U. S. PATENT DOCUMENTS**

| EXAMINER INITIAL | DOCUMENT NUMBER | DATE | NAME | CLASS | SUB CLASS | FILING DATE IF APPROP. |
|---|---|---|---|---|---|---|
| SMC | 5 3 0 6 7 4 4 | 04.1994 | WOLFERSBERGER et al. | | | |
| | 5 4 0 9 9 7 1 | 04/1995 | WOLFERSVERGER et al. | | | |
| SMC | 4 0 3 3 9 2 0 | 07/1977 | ISOZAKI et al. | | | |

**FOREIGN PATENT DOCUMENTS**

| | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUB CLASS | Translation Yes | Translation No |
|---|---|---|---|---|---|---|---|
| SMC | WO 98/58912 | 12/1998 | PCT | | | X | |
| | JP 6211950 V | 08/1994 | JAPAN | | | X | |
| | JP 5009247 V | 01/1993 | JAPAN | | | X | |
| | JP 51017922 ✓ | 02/1976 | JAPAN | | | X | |
| SMC | JP 51023531 ✓ | 02/1976 | JAPAN | | | X | |

**OTHER DOCUMENTS** (Including Author, Title, Date, Pertinent Pages, Etc.)

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| EXAMINER | DATE CONSIDERED |
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| Sayan McClure | 1/3/03 |

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| | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUB CLASS | Translation Yes | Translation No |
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| SMC | JP 2000/234044 ✓ | 08/2000 | JAPAN | | | X | |
| SMC | JP 2000/234045 ✓ | 08/2000 | JAPAN | | | X | |
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| SMC | ✓RadTech Europe 95, Exhibit & Conference for Radiation Curing, September 24-27, 1995, in Maastricht/NL |
| SMC | ✓H. Anderson & A. Hult, "Initiator-Free Photopolymerization of an Aliphatic Vinyl Ether-Maleimide Monomer, Dept. of Polymer Technology, Vol. 69, No. 865, February 1997 |
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